

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IFW

Applicant(s): KUMAR et al.

Atty. Dkt.: 01-549

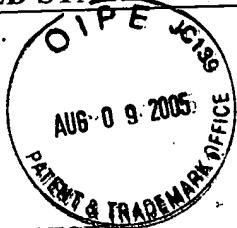
Serial No.: 10/776,338

Group Art Unit: 2814

Filed: February 12, 2004

Examiner: CAO, Phat X

Title: SEMICONDUCTOR DEVICE
PROVIDED BY SILICON CARBIDE
SUBSTRATE AND METHOD FOR
MANUFACTURING THE SAME



August 9, 2005

Commissioner for Patents
Alexandria, VA 22314

RESPONSE TO RESTRICTION REQUIREMENT/ELECTION OF SPECIES

Sir:

In response to the Restriction Requirement/Election of Species mailed on July 21, 2005 in connection with the above application, Applicants hereby elect Invention I of claims 1-9 (drawn to semiconductor device structures) and Species I with traverse. Applicants state that claims 1-3, 5 and 8-9 read on this Species I.

Examination of the present application in view of the above election is respectfully requested.

Please charge any necessary fees to Deposit Account 50-1147.

Respectfully submitted,

A handwritten signature in black ink, appearing to read "DGP".

David G. Posz
Reg. No. 37,701

DGP/moa
Posz Law Group, PLC
11240 South Lakes Drive, Suite 101
Reston, VA 20191
(703)707-9110 (phone)
Customer No. 23400